

# Non-Fermi Liquids and Bad Metals in NdNiO<sub>3</sub> Thin Films

Susanne Stemmer

*Materials Department*

*University of California, Santa Barbara*

Workshop on Bad Metal Behavior in Mott Systems  
Schloß Waldhausen, Germany  
June 29, 2015

# Acknowledgements

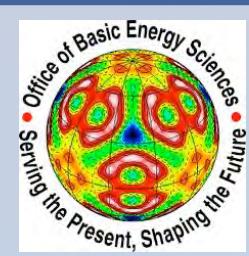
## ■ Graduate students and postdocs:

- Evgeny Mikheev
- Adam Hauser
- Nelson Moreno
- Jinwoo Hwang (now at OSU)
- Jack Zhang
- Junwoo Son (now at Postech)

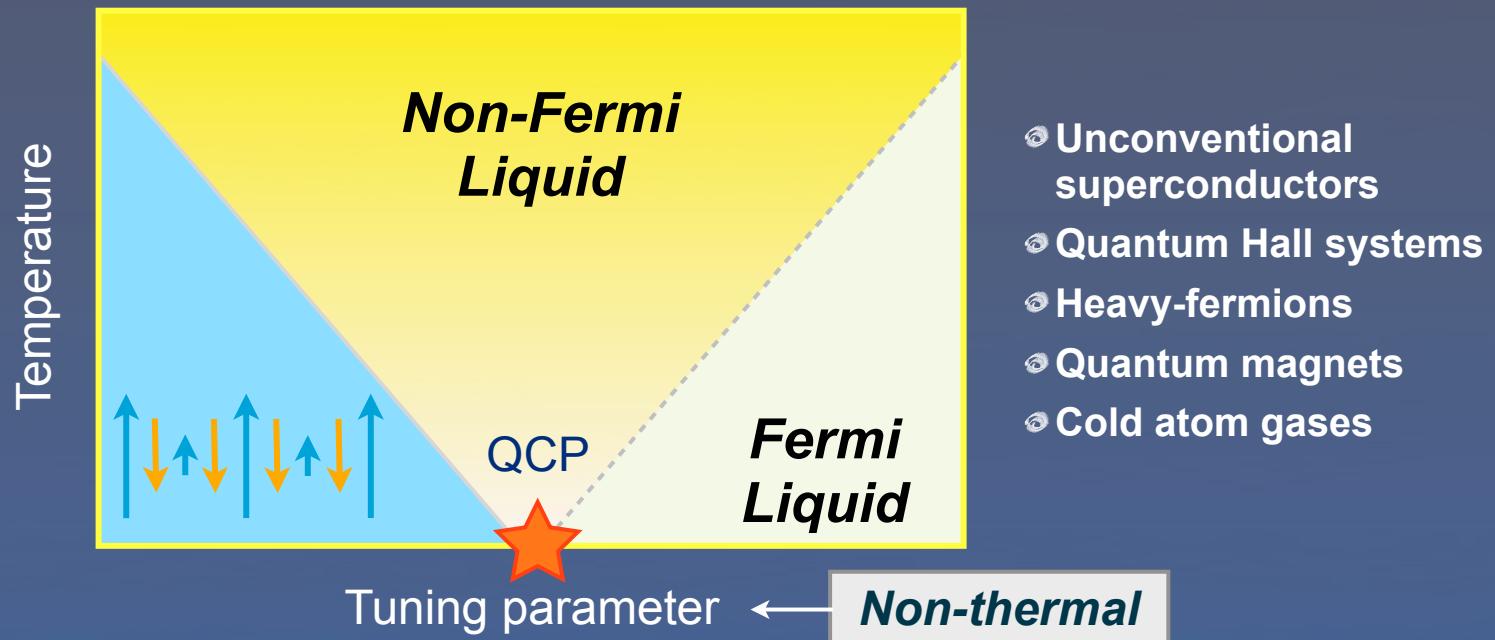


## ■ Collaborators: Burak Himmetoglu, Chris Van de Walle (UCSB Materials)

## ■ Funding



# Quantum Criticality



- ⦿ Continuous phase transition at zero-temperature
- ⦿ Quantum fluctuations influence the material over a wide range of temperatures and across phase diagram

A non-thermal control parameter causing large changes in properties: metal-insulator transitions, magnetic transitions, ...

# Quantum Criticality

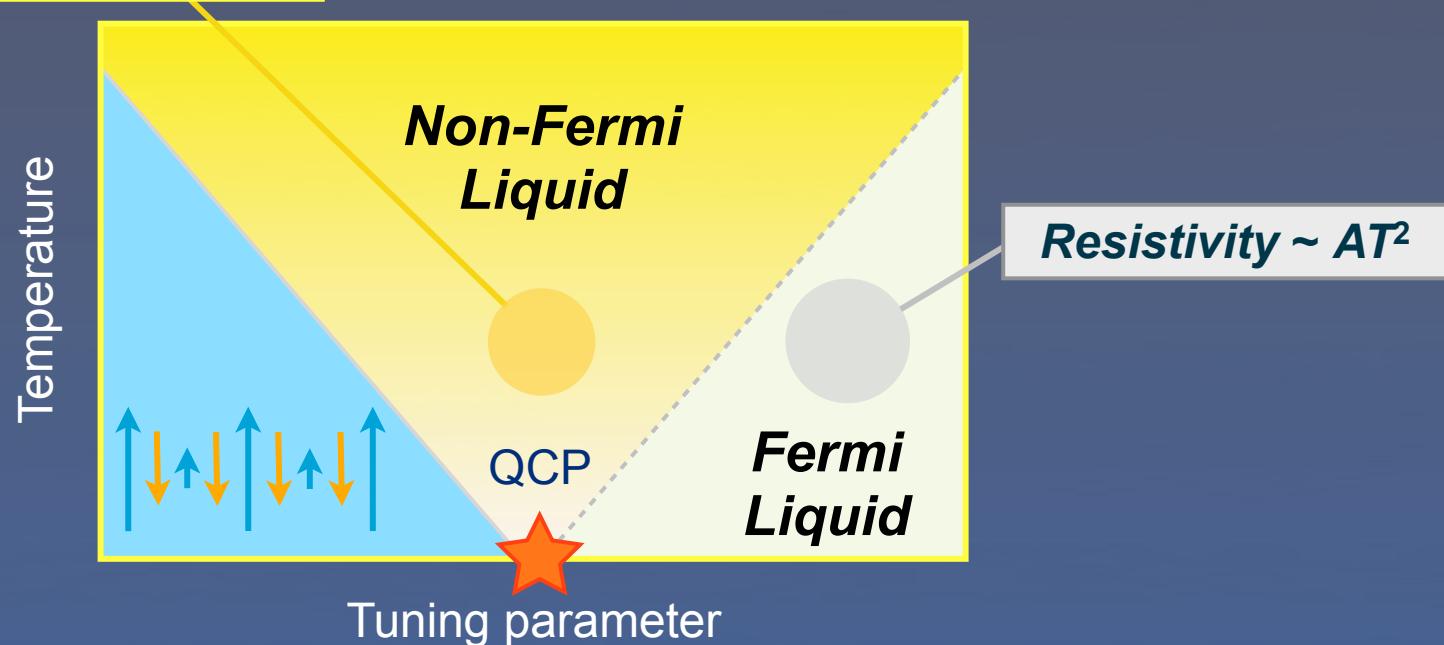
Proc. Natl. Acad. Sci. USA  
Vol. 92, pp. 6668–6674, July 1995  
Colloquium Paper



New physics of metals: Fermi surfaces without Fermi liquids

P. W. ANDERSON

$\text{Resistivity} \sim AT^n$



## Non-Fermi liquid behavior:

- Poorly understood power laws in transport coefficients
- Non-saturating resistances that escalate past the Mott-loffe-Regel limit: “Strange Metals”
- Strong temperature dependence of the Hall coefficient (not reflecting a real change in Fermi surface)

# Bad Metals

VOLUME 74, NUMBER 16

PHYSICAL REVIEW LETTERS

17 APRIL 1995

## Superconductivity in Bad Metals

V. J. Emery

*Department of Physics, Brookhaven National Laboratory, Upton, New York 11973*

S. A. Kivelson

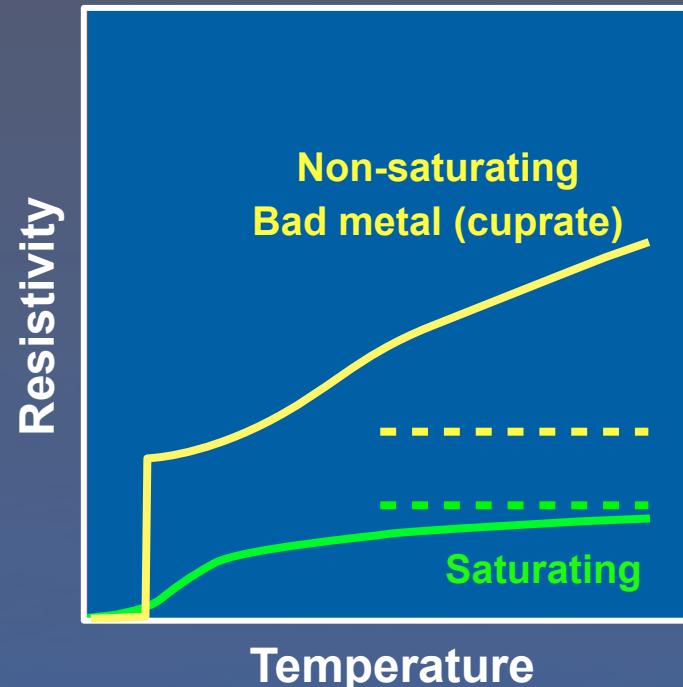


- Mott-loffe-Regel limit: mean free path length  $\sim$  lattice spacing
- Neither saturating nor non-saturating metals are understood

P. B. Allen, Physica B 318, 24-27 (2002); O. Gunnarsson, et al., Nature 405, 1027 (2000); B. Chakraborty, and P.B. Allen, Phys. Rev. Lett. 42, 736-738 (1979); M. Calandra, and O. Gunnarsson, Phys. Rev. B 66, 205105 (2002); P. B. Allen, Nature 405, 1007 (2000); Millis, A.J., Hu, J., & Sarma, S.D., Phys. Rev. Lett. 82, 2354-2357 (1999); O. Gunnarsson, et al., RMP 75, 1085 (2003); N. E. Hussey, K. Takenaka, & H. Takagi, Phil. Mag. 84, 2847 (2004).

- Saturating metals are described by:

$$\frac{1}{\rho} = \frac{1}{\rho_0 + AT^n} + \frac{1}{\rho_{\text{sat}}} \quad \left. \right\}$$



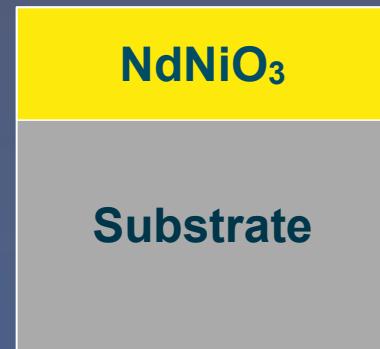
$$\rho_{\text{MIR}} = \frac{3\pi^2 \hbar}{q^2 k_F^2 a}$$

Mott-loffe-Regel limit

Mott-loffe-Regel limit

- Electron-electron scattering:  $n \sim 2$
- Non-Fermi liquids:  $n < 2$
- $\rho_0$ : residual resistance (disorder)
- Saturation resistance connected in parallel, serves to reduce resistance

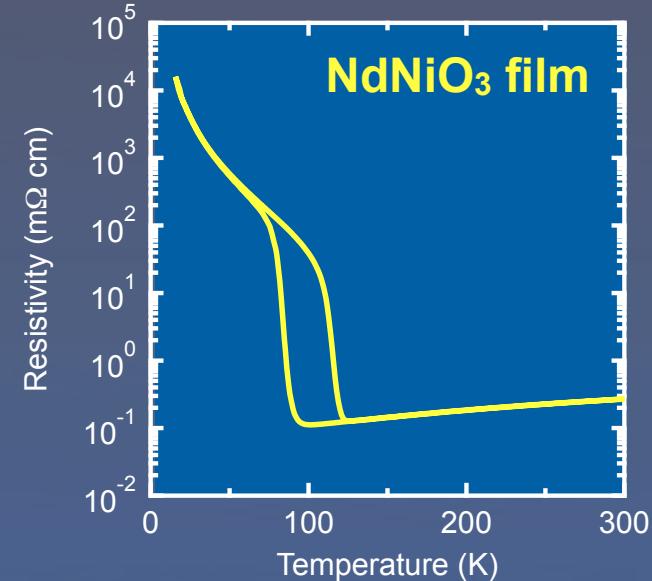
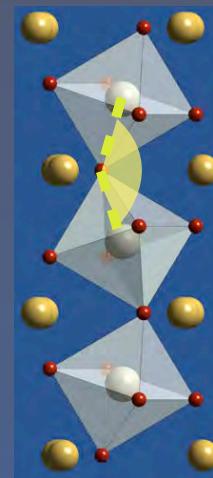
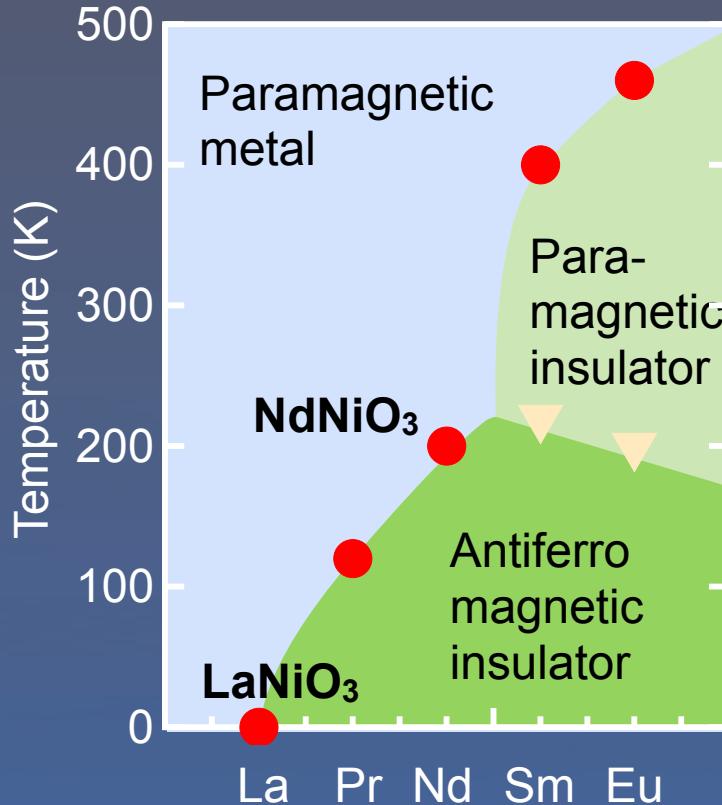
# This talk:



## Non-Fermi liquid behavior in strained NdNiO<sub>3</sub> thin films:

- ⦿ NFL power law coefficients in resistivity
- ⦿ Quantum critical point
- ⦿ Bad metal behavior
- ⦿ Vary strain and confinement (thickness): relationship to electronic structure

# Metal-Insulator Transitions in $R\text{NiO}_3$

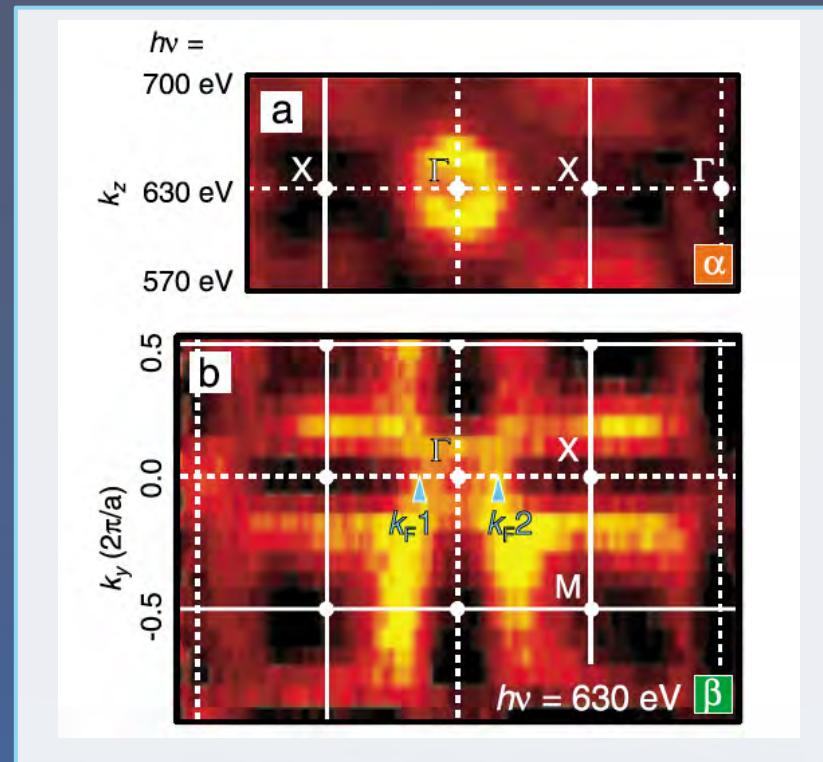


J. B. Torrance, et al., Phys. Rev. B 45, 8209 (1992). J. M. Rondinelli, S. J. May, and J. W. Freeland, MRS Bulletin (March 2012).

A. J. Hauser, et al., Appl. Phys. Lett. 106, 092104 (2015).

- Quantum phase transition
- Size of the rare earth ion is the tuning parameter: “band-width driven metal-insulator transition”
- Expect the transition to be sensitive to strain
- Is the transition quantum critical?
- Non-Fermi liquid behavior?

# Orbital Engineering in $R\text{NiO}_3$



R. Eguchi, et al., Phys. Rev. B 79, 115122 (2009).

PRL 103, 016401 (2009)

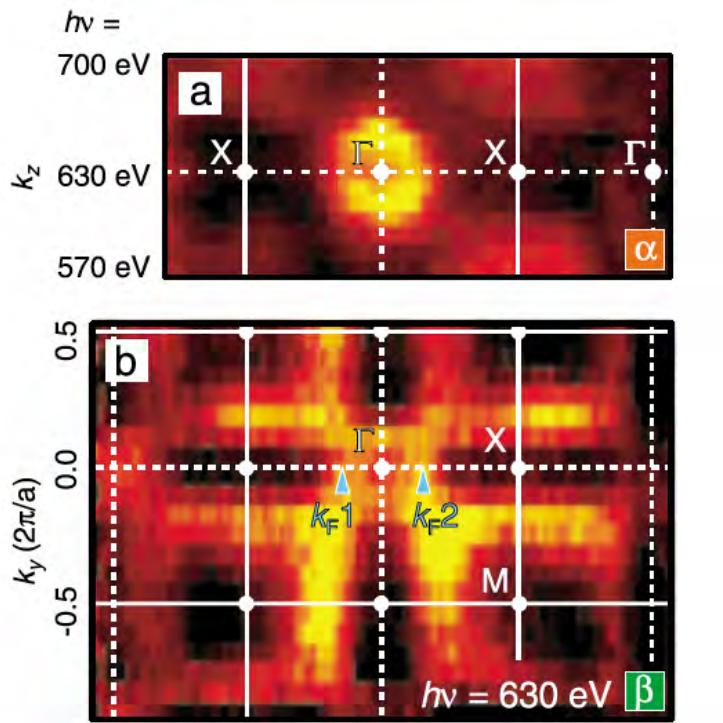
PHYSICAL REVIEW LETTERS

week ending  
3 JULY 2009

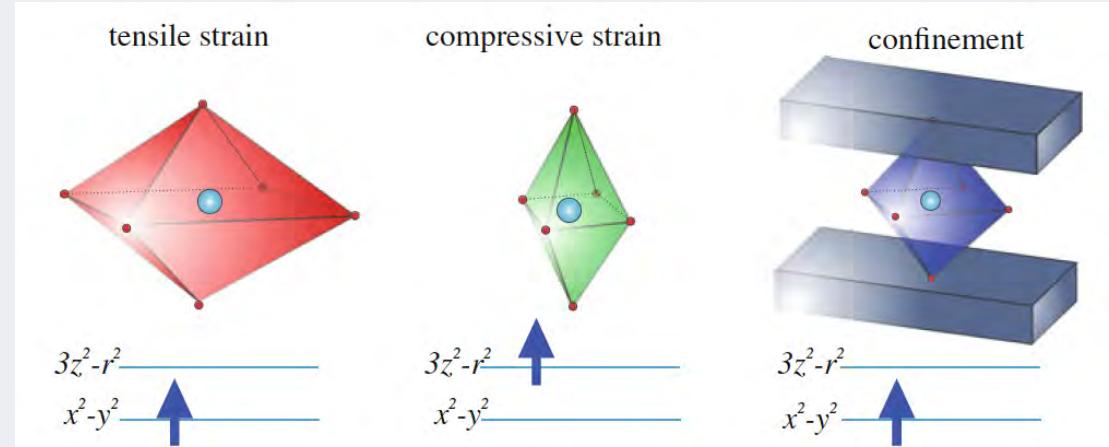
## Turning a Nickelate Fermi Surface into a Cupratelike One through Heterostructuring

P. Hansmann,<sup>1,2</sup> Xiaoping Yang,<sup>1</sup> A. Toschi,<sup>1,2</sup> G. Khaliullin,<sup>1</sup> O. K. Andersen,<sup>1</sup> and K. Held<sup>2</sup>

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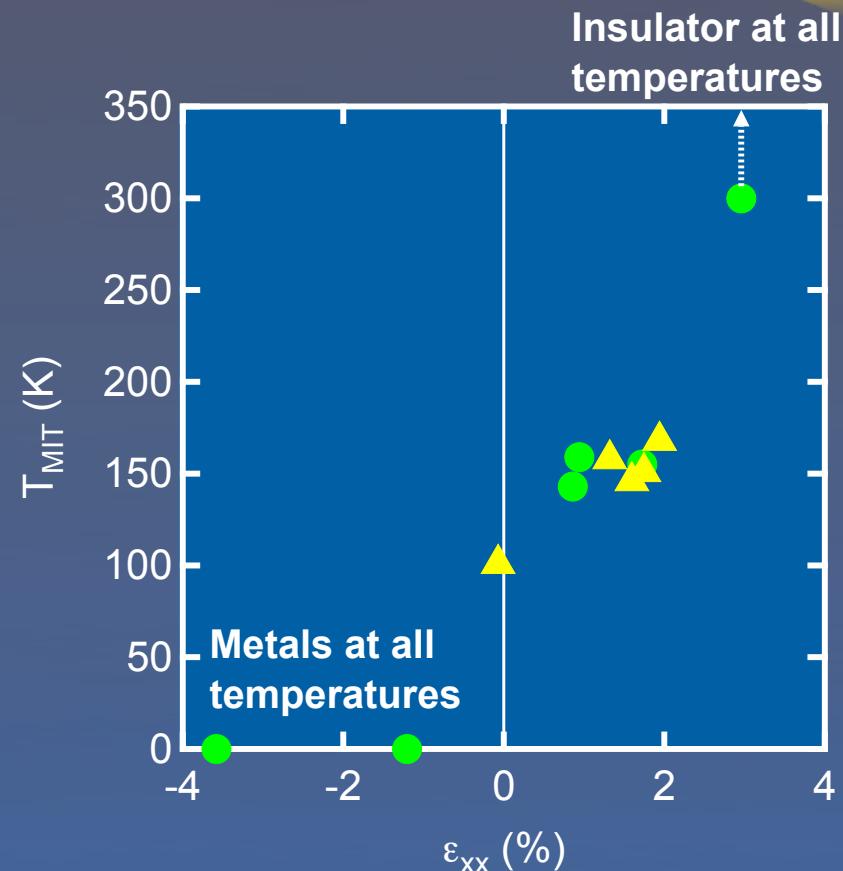
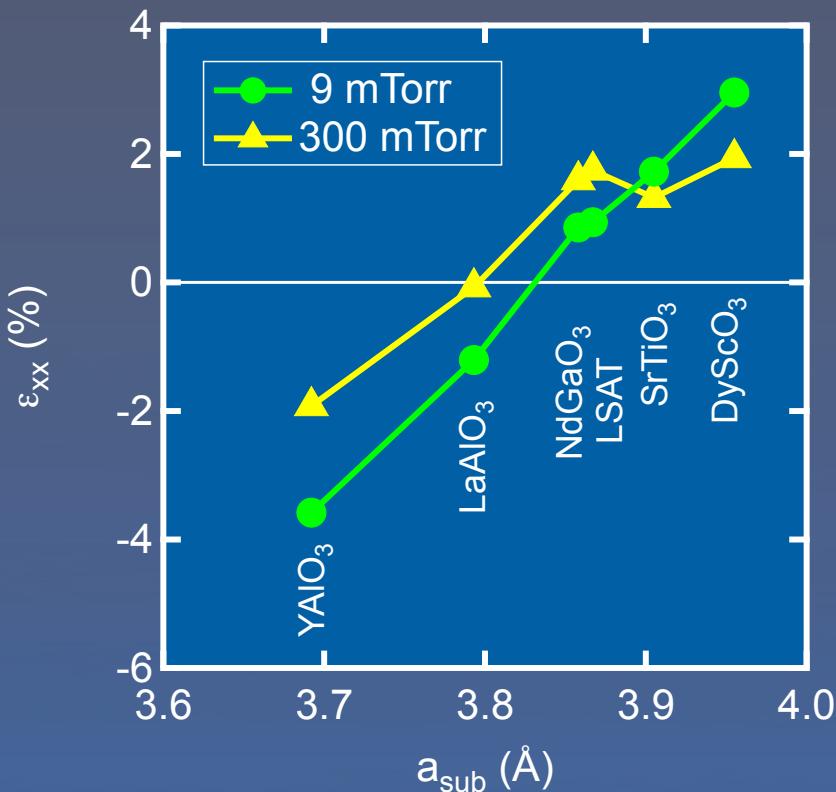


A. Frano, Spin Spirals and Charge Textures in Transition-Metal-Oxide Heterostructures (Ph.D. thesis, 2014), Springer.

O. E. Peil et al., Phys. Rev. B 90, 045128 (2014); E. Benckiser, et al., Nat. Mater. 10, 189 (2011); J.W. Freeland, et al., EPL 96, 57004 (2011); A.V. Boris, et al., Science 332, 937 (2011); M. Wu et al., Phys. Rev. B 88, 125124 (2013); H. K. Yoo, et al., Sci. Rep. 5, 8746 (2015); S. B. Lee et al., Phys. Rev. Lett. 106, 016405 (2011).

- Tensile strains and confinement favor the large hole surface
- Promotes a spin density wave instability and insulating state
- Confinement and tensile strains have qualitatively similar effects

# Strain as a Tuning Parameter



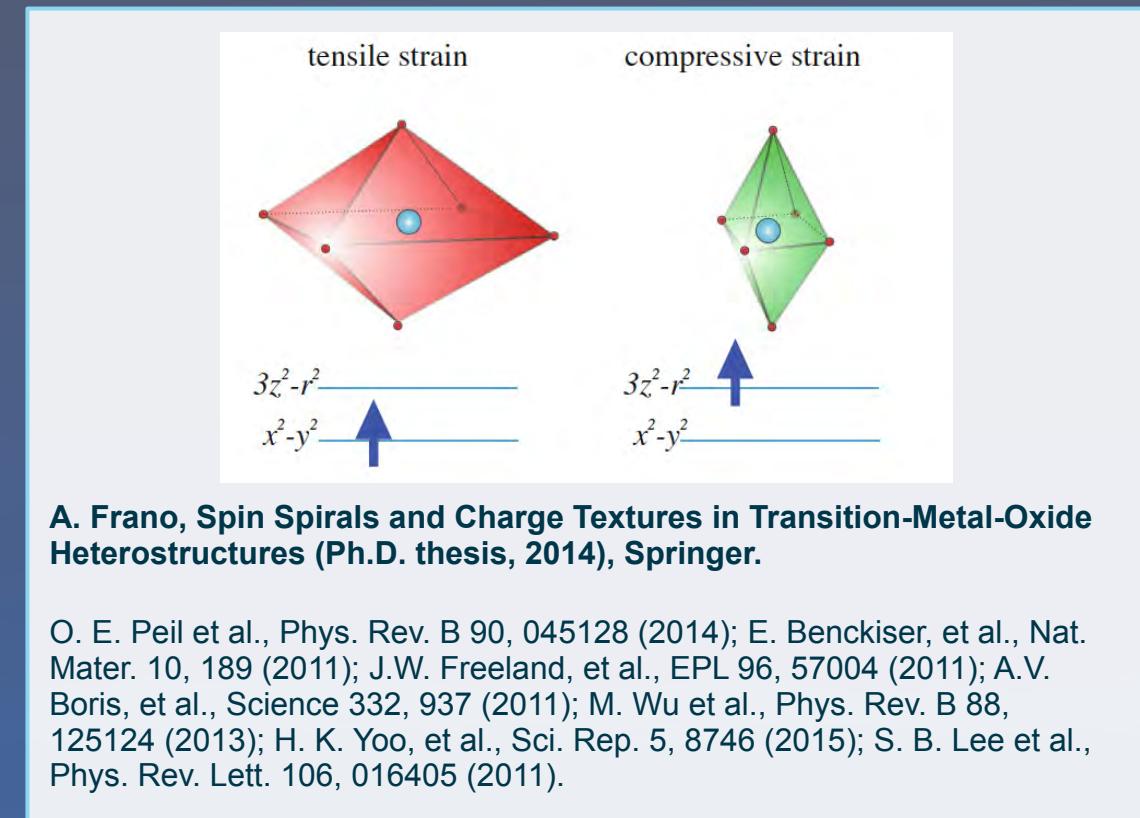
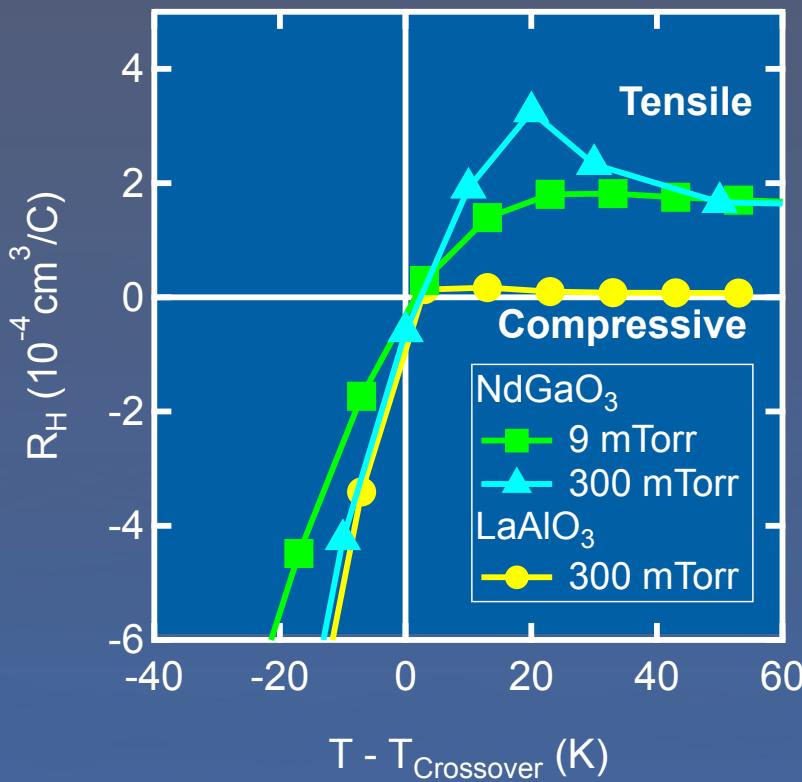
A. J. Hauser, et al., Appl. Phys. Lett. 106, 092104 (2015).

- Epitaxial strain systematically shifts the MIT
- MIT is relatively independent of deposition conditions, which affect the stoichiometry
- Low-pressure films can be strained to larger strains without relaxing

# Orbital Engineering in $R\text{NiO}_3$

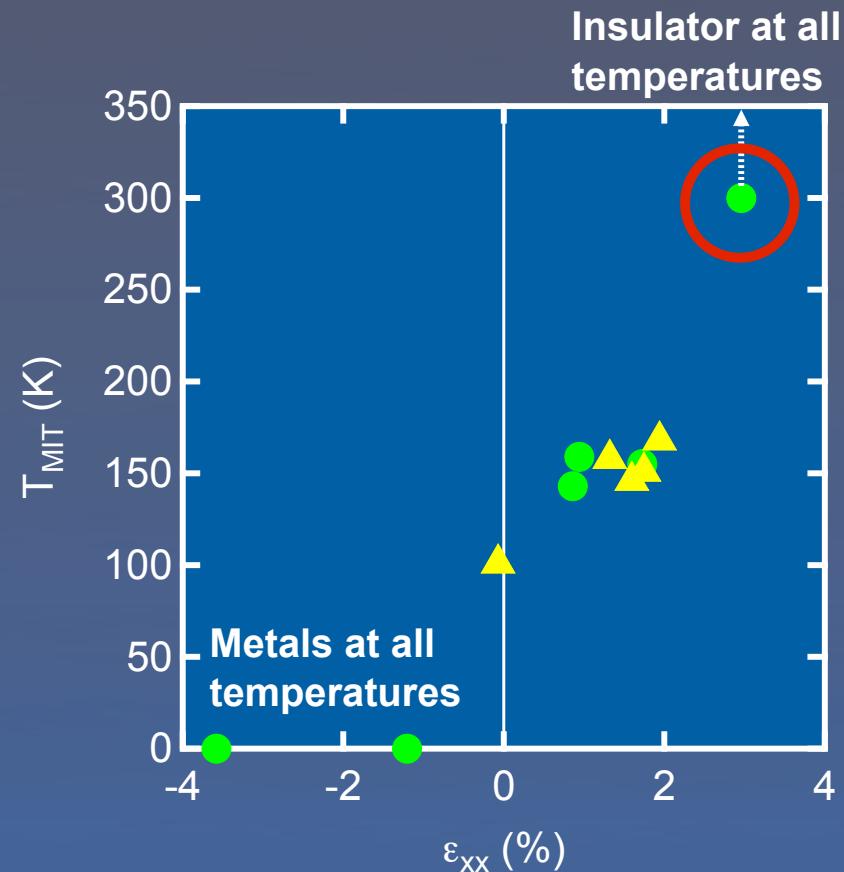
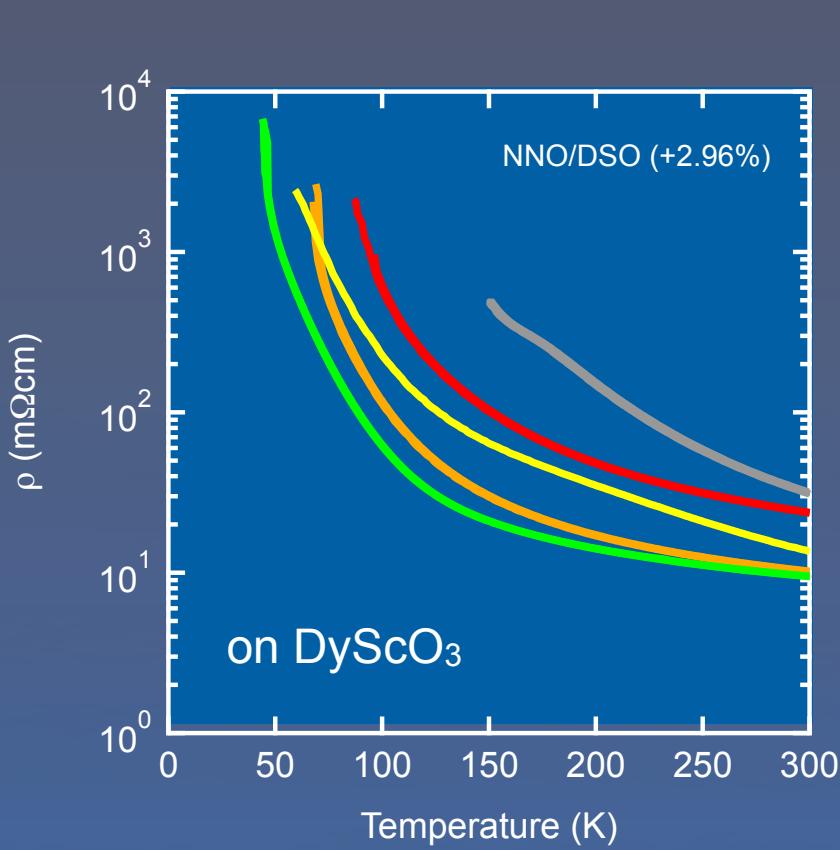


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# Strain as a Tuning Parameter



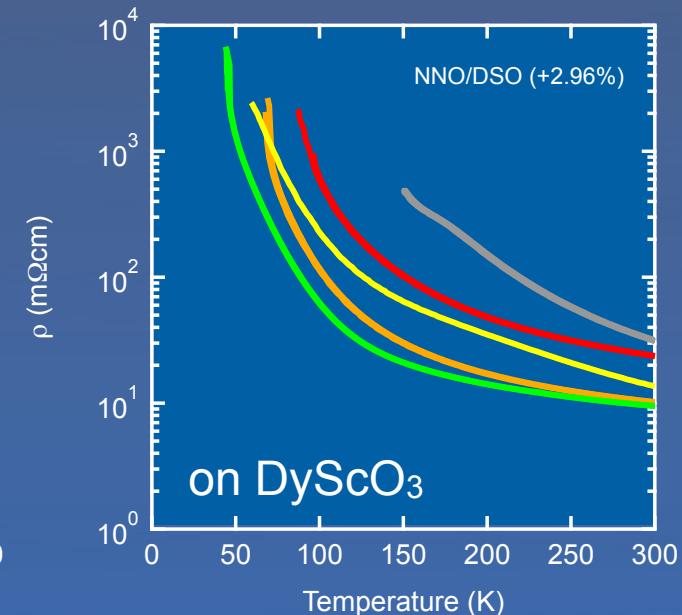
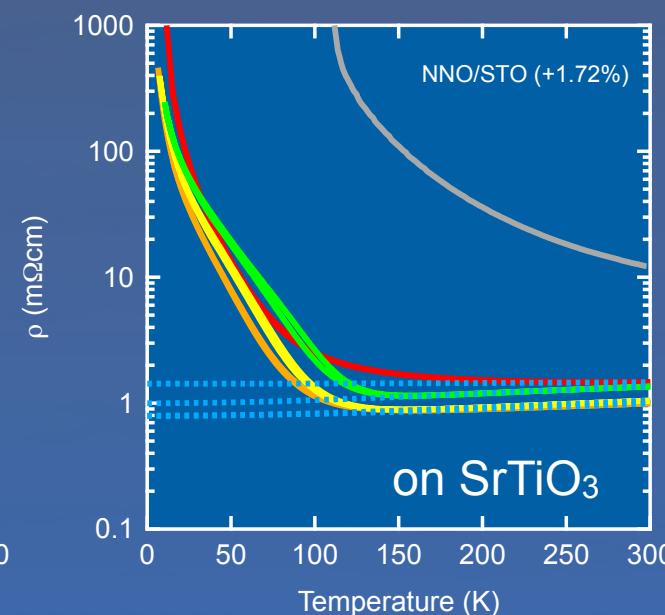
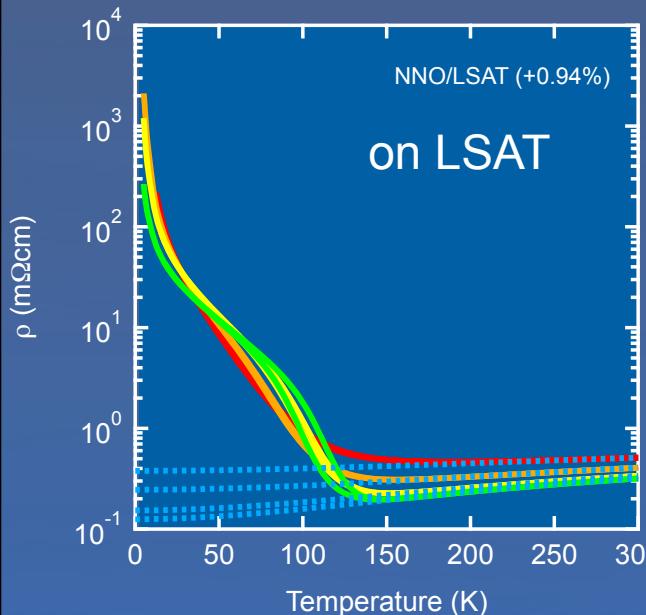
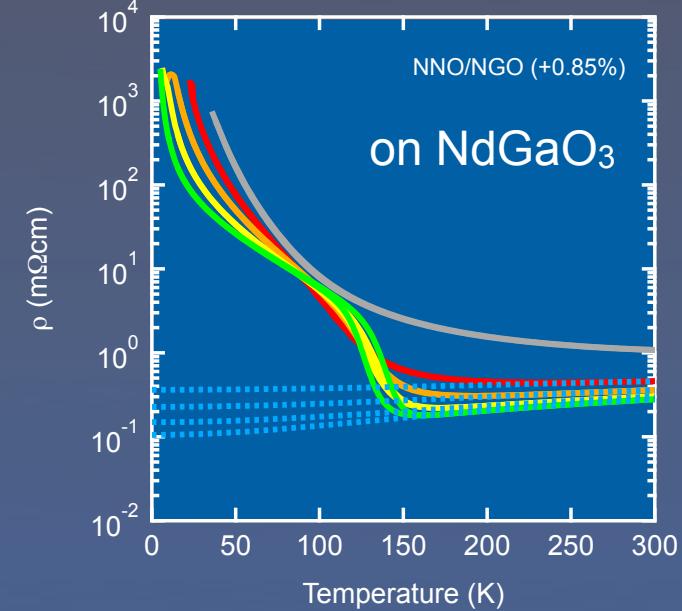
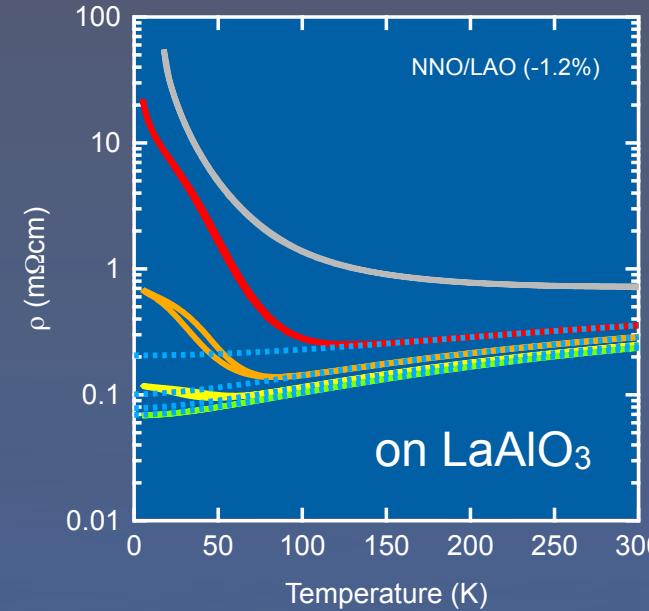
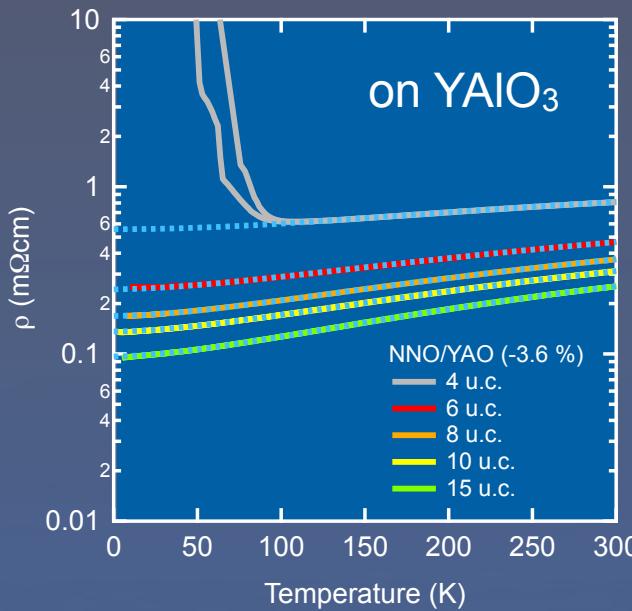
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Likely more complex reasons for films with insulating state at all temperature than simple band width tuning

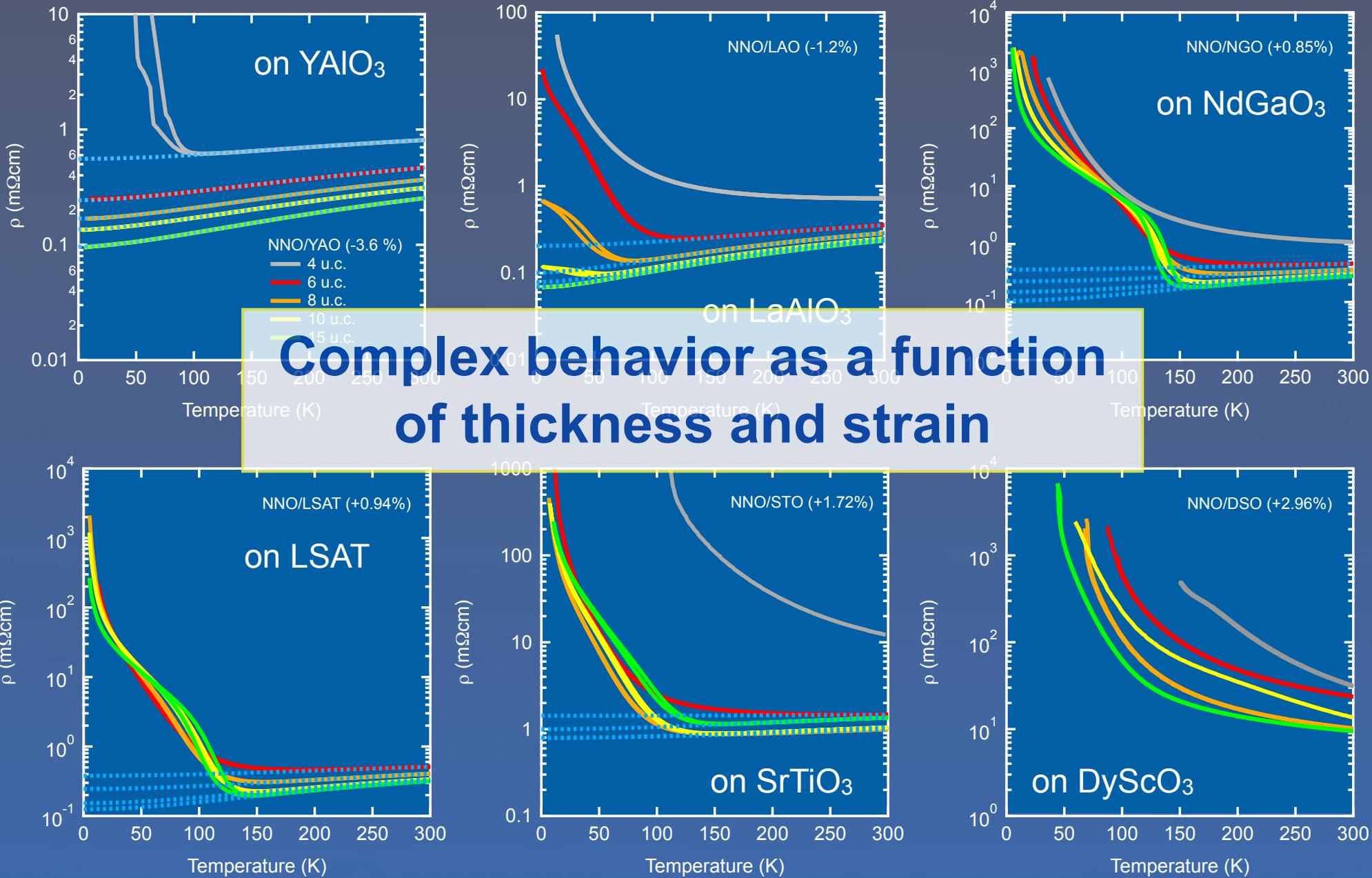
Role of disorder?

Criterion for Anderson transition in this system?

# Metal-Insulator Transitions in NdNiO<sub>3</sub>

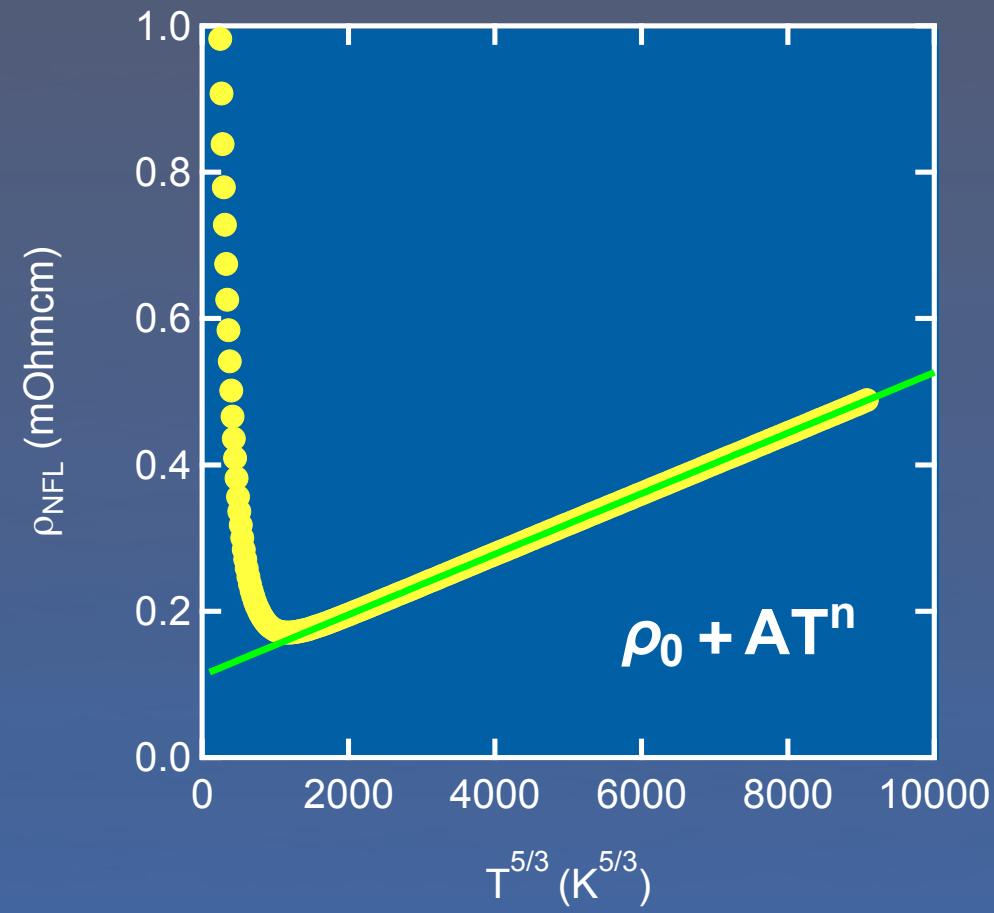
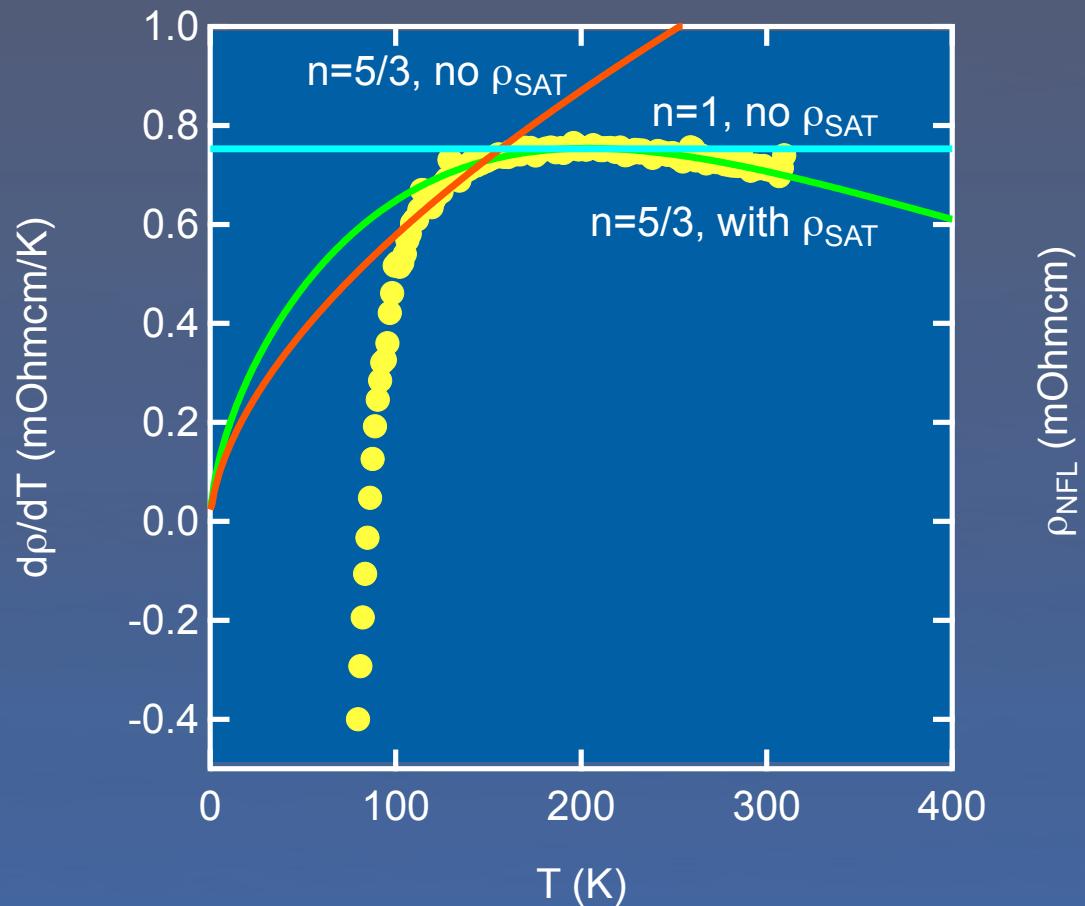


# Metal-Insulator Transitions in NdNiO<sub>3</sub>



# MITs and Non-Fermi Liquids

$$\frac{1}{\rho} = \frac{1}{\rho_0 + AT^n} + \frac{1}{\rho_{sat}}$$

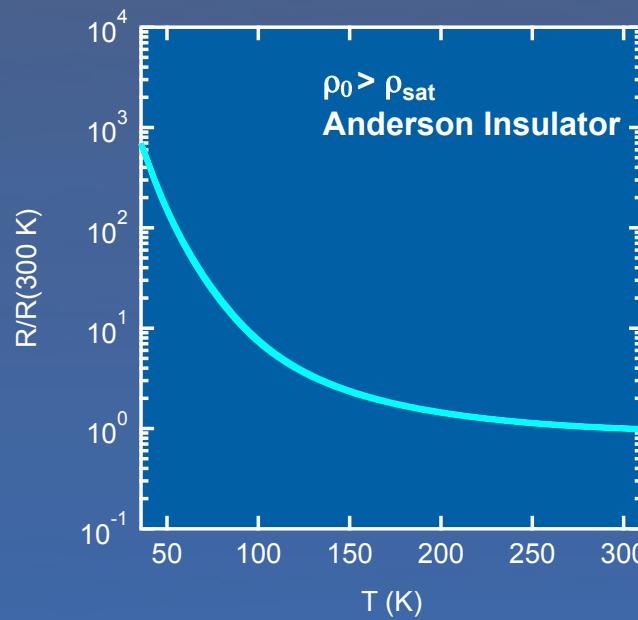
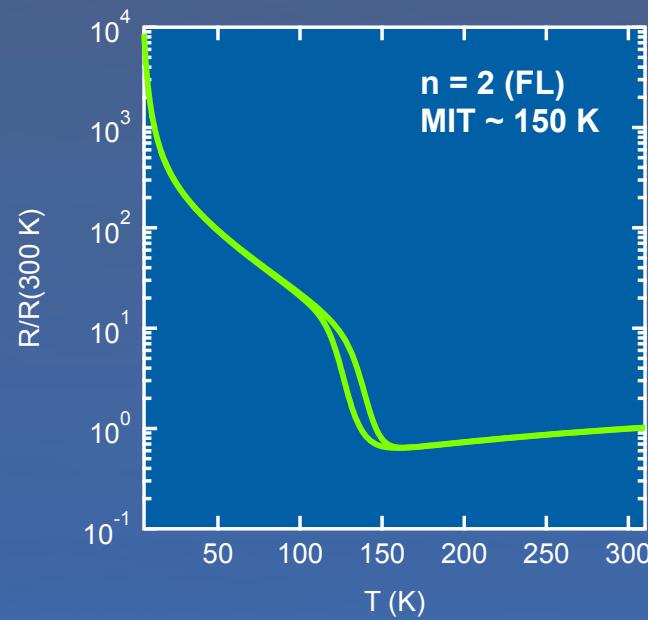
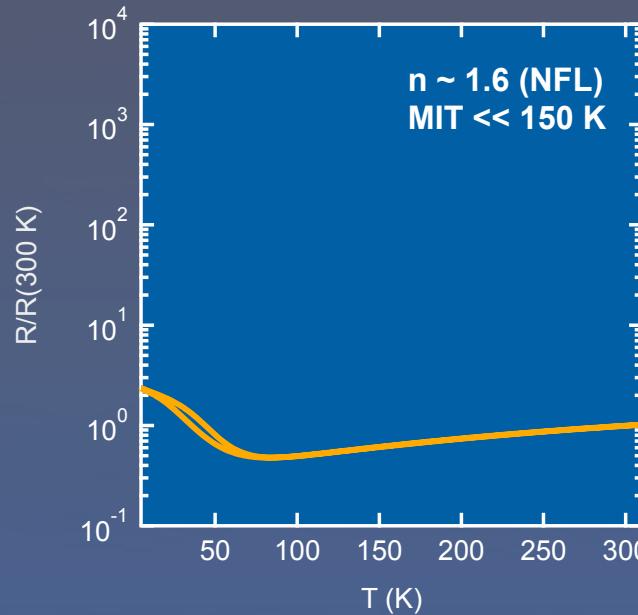
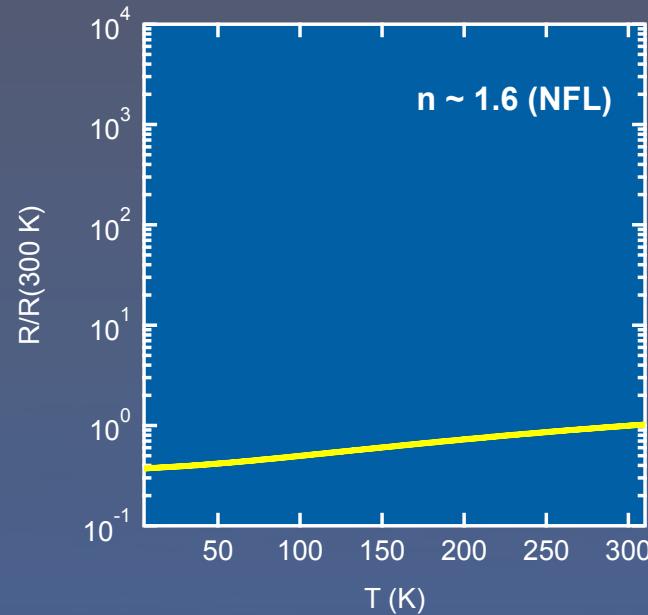


E. Mikheev, et al., arXiv:1507.06619 [cond-mat.str-el]

- Metallic phase exhibits saturating resistance
- Need to take into account to get correct NFL exponent

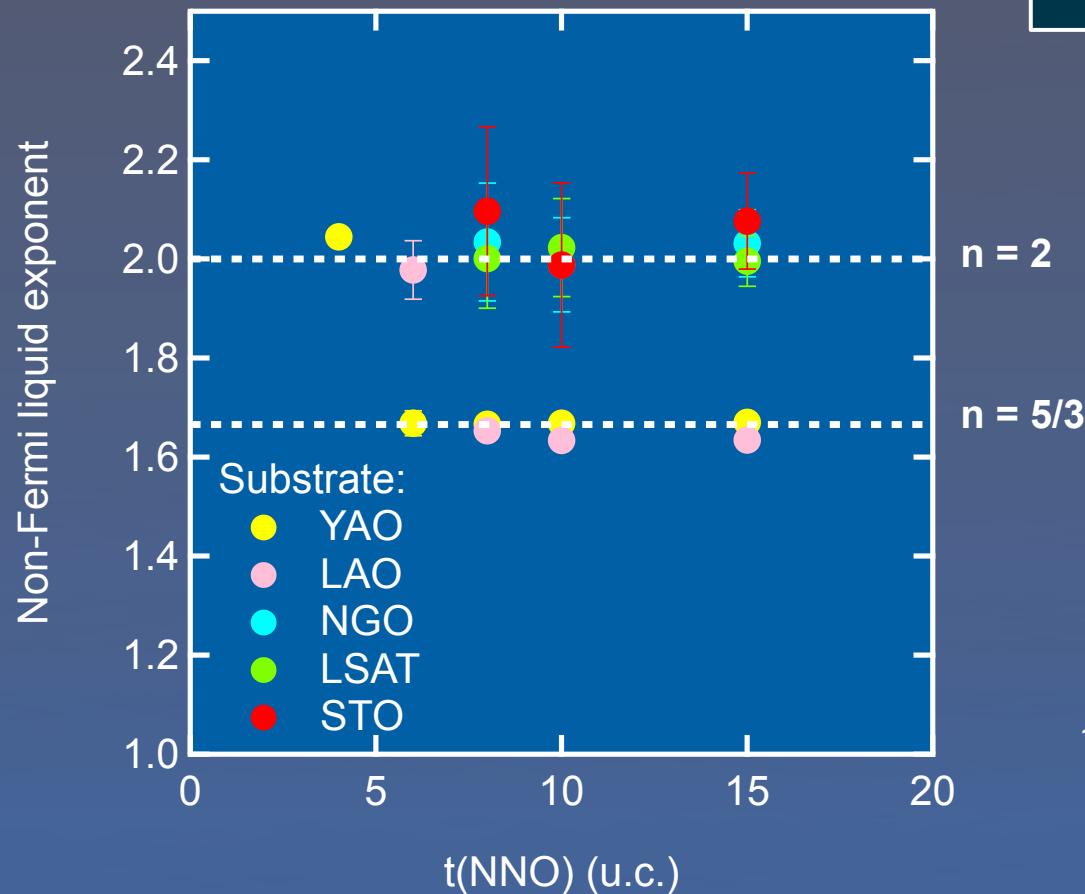
# MITs and Non-Fermi Liquids

$$R = R_0 + A T^n$$



# MITs and Non-Fermi Liquids

$$\frac{1}{\rho} = \frac{1}{\rho_0 + A T^n} + \frac{1}{\rho_{\text{sat}}}$$

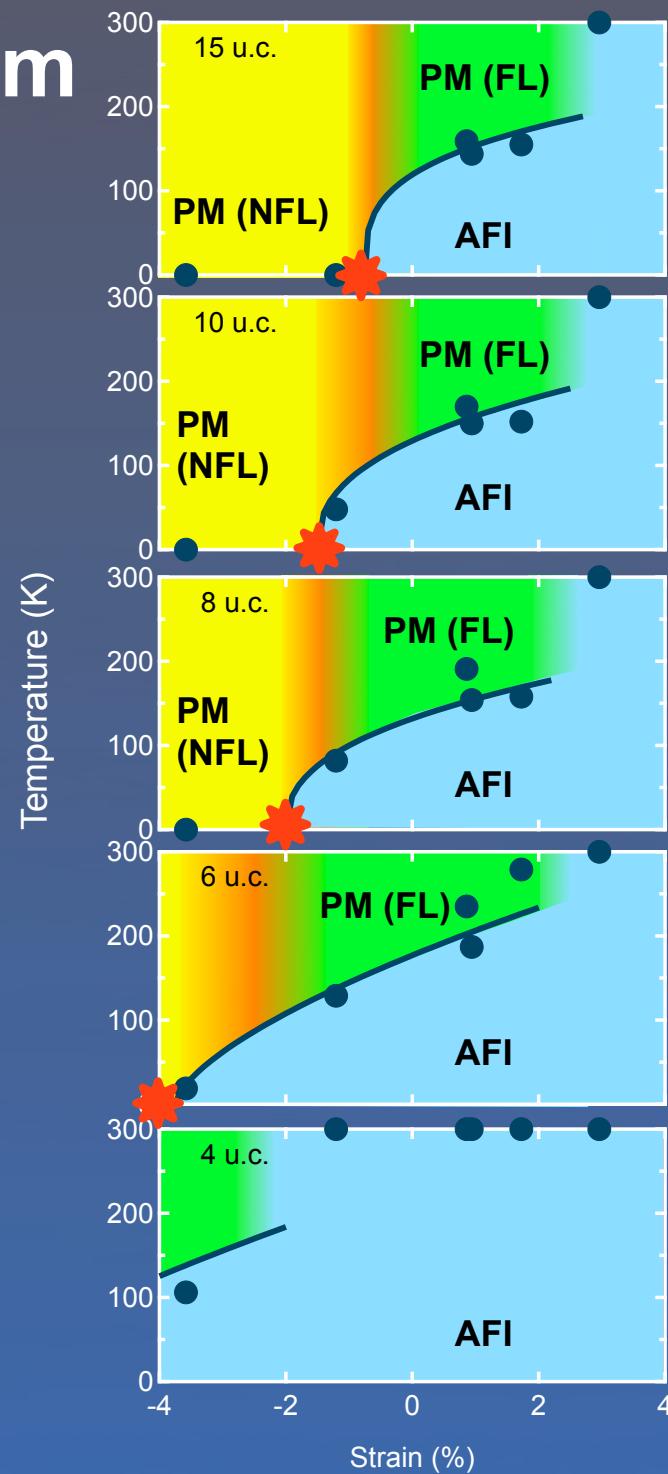
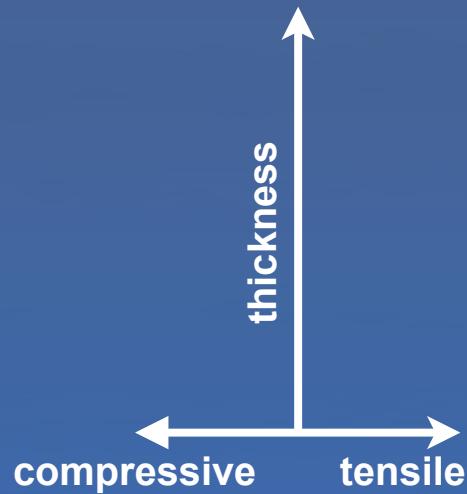


E. Mikheev, et al., arXiv:  
1507.06619 [cond-mat.str-el]

- Non-Fermi liquid behavior *only if MIT is suppressed*
- Same exponent ( $5/3$ ) across the entire sample series
- $n$  is independent of disorder
- Need to take resistance saturation into account to get correct  $n$

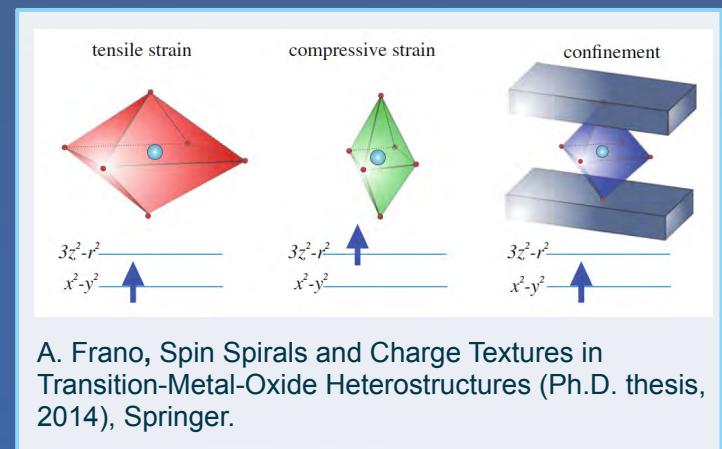
# Phase Diagram

$$\frac{1}{\rho} = \frac{1}{\rho_0 + A T^n} + \frac{1}{\rho_{\text{sat}}}$$



- Quantum critical point shifts to more compressive strains with decreasing film thickness
- Confinement promotes  $x^2-y^2$  orbital polarization, which favors spin density wave and the AFM insulator
- Suppression of MIT leads to NFL behavior

E. Mikheev, et al., arXiv:1507.06619  
[cond-mat.str-el]



A. Frano, Spin Spirals and Charge Textures in Transition-Metal-Oxide Heterostructures (Ph.D. thesis, 2014), Springer.

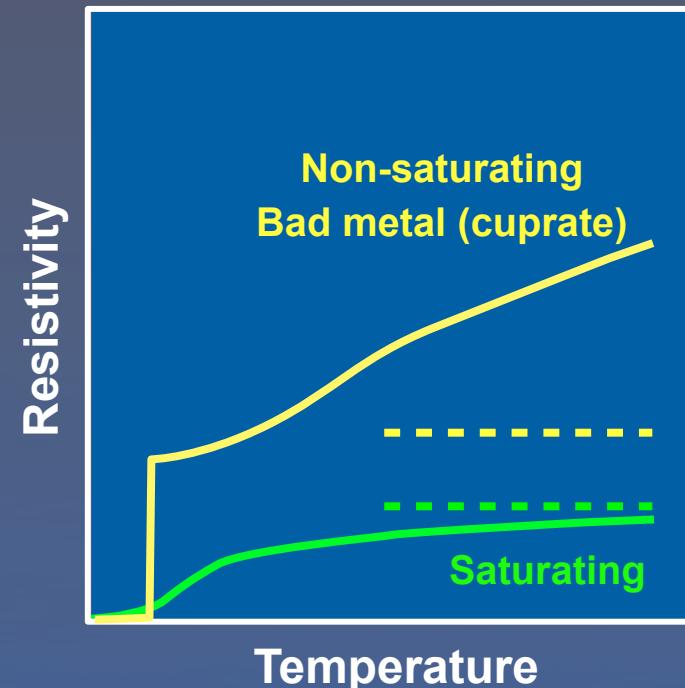
# Bad Metals

- Mott-loffe-Regel limit: mean free path length ~ lattice spacing
- Neither saturating nor non-saturating metals are understood

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**Mott-loffe-Regel limit**

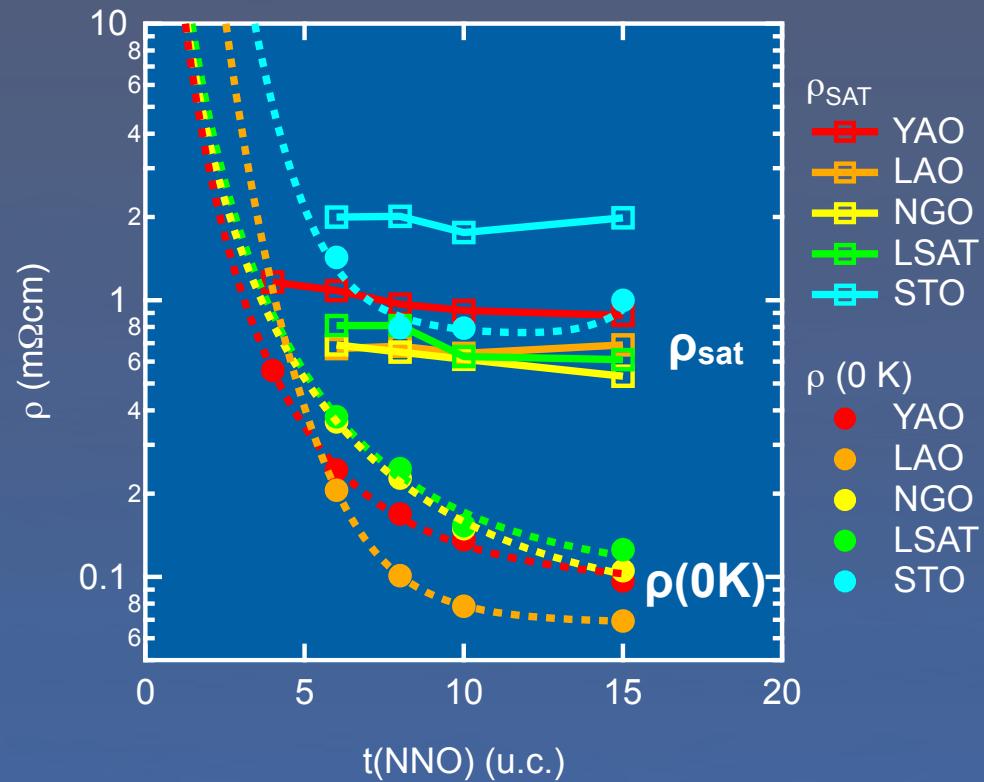
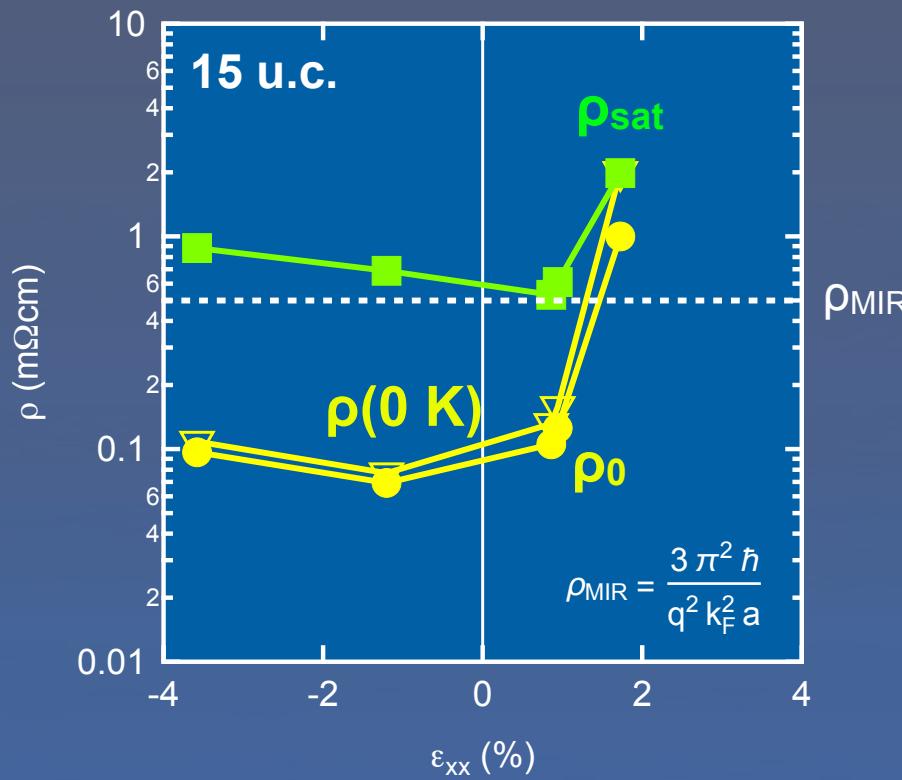
**Mott-loffe-Regel limit**

- Electron-electron scattering:  $n \sim 2$
- Non-Fermi liquids:  $n < 2$
- $\rho_0$ : residual resistance (disorder)
- Saturation resistance connected in parallel, serves to reduce resistance

# Saturating Metallic Phase

In the 0-K limit:

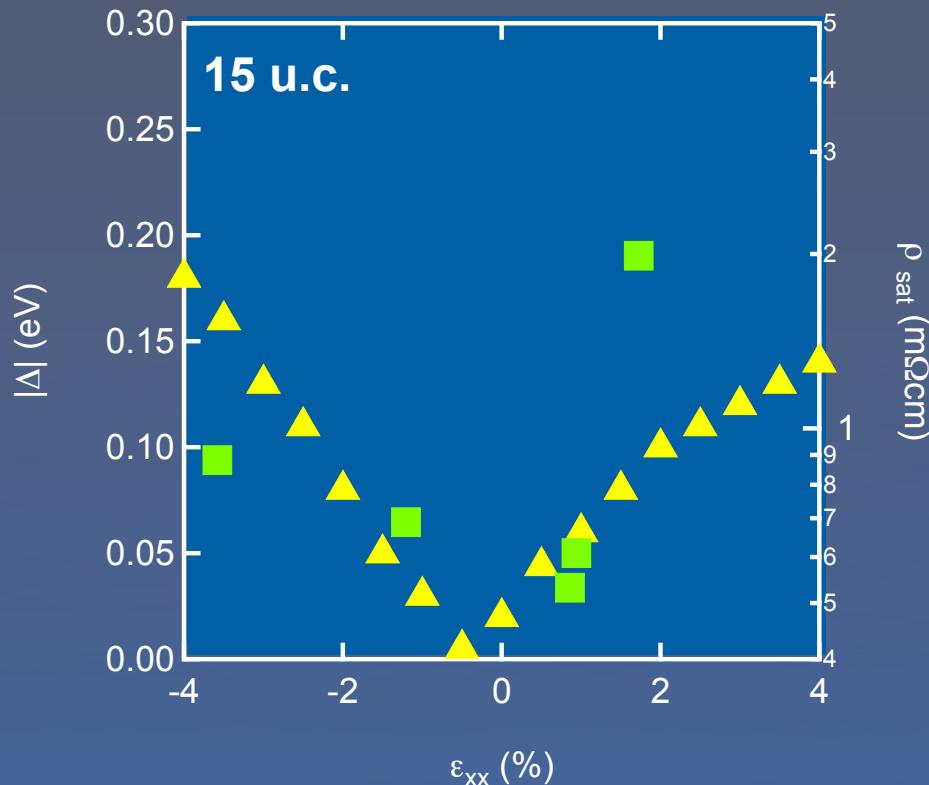
$$\frac{1}{\rho(0 \text{ K})} = \frac{1}{\rho_0} + \frac{1}{\rho_{\text{sat}}}$$



- $\rho_{\text{sat}}$  and  $\rho_0$  depend on the magnitude of the mismatch strain

- $\rho_{\text{sat}}$  is independent of thickness (confinement, disorder)
- $\rho_0$  strongly depends on thickness

# Saturation and Orbital Polarization



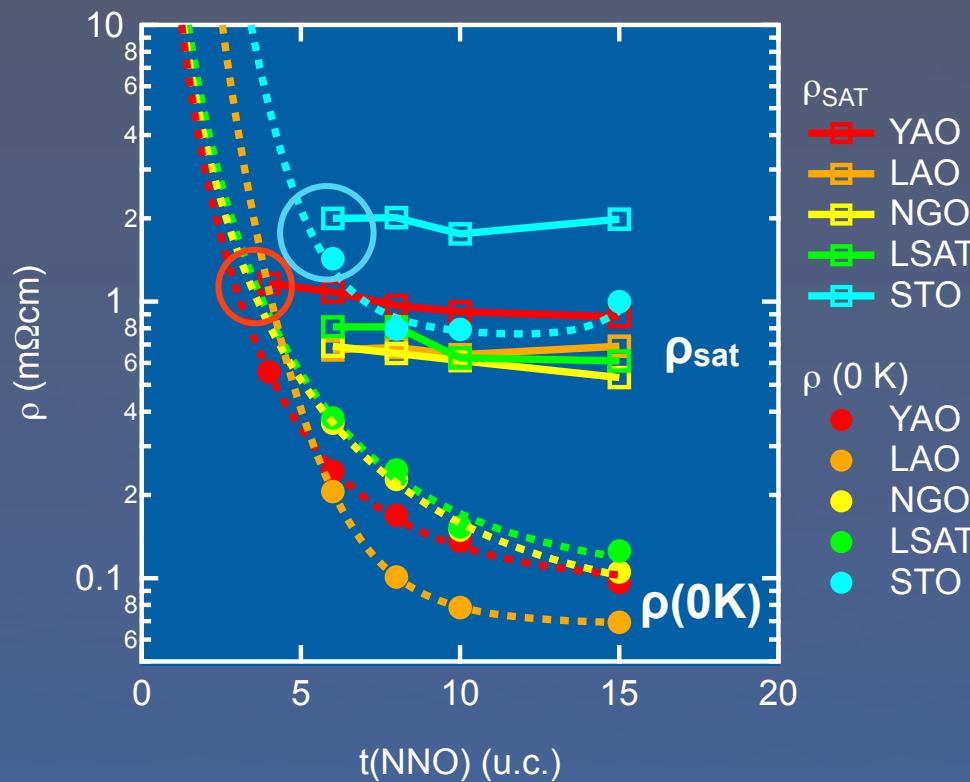
- $\rho_{sat}$  depends on the magnitude of orbital polarization
- A parallel channel due to interband scattering
- Conversely, predict that materials with a single band at the Fermi level show no saturation (i.e., cuprates)

- Consistent with theoretical predictions (modified Boltzmann transport models that account for interband scattering and QMC simulations)

P. B. Allen, Physica B 318, 24-27 (2002); O. Gunnarsson, et al., Nature 405, 1027 (2000); B. Chakraborty, and P.B. Allen, Phys. Rev. Lett. 42, 736-738 (1979); M. Calandra, et al., Phys. Rev. B 66, 205105 (2002).

- $\rho_{sat}$  is tunable by orbital polarization

# Criterion for the “Anderson Insulator”: $\rho_{\text{sat}} \sim \rho_0$

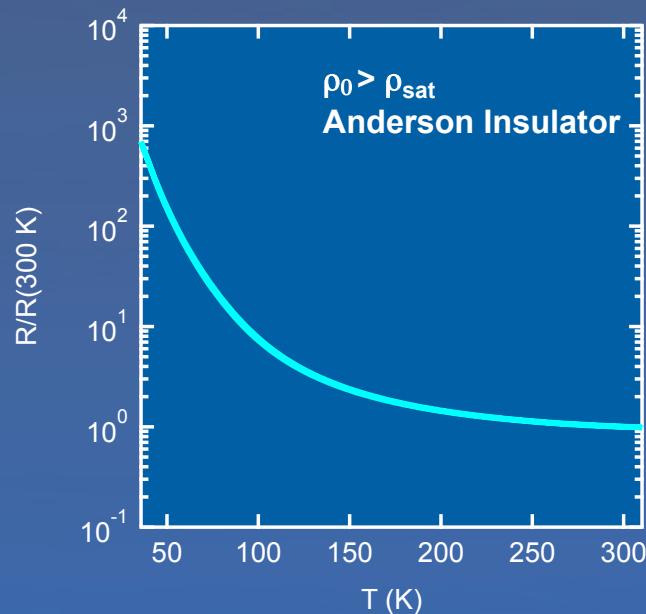
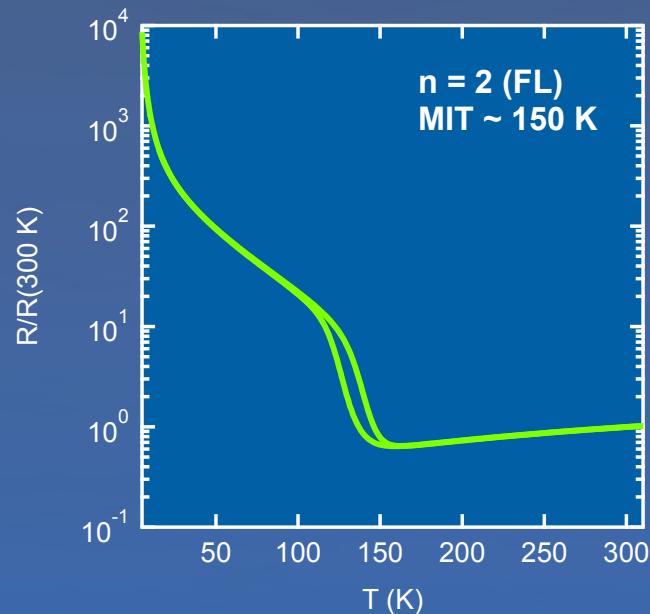
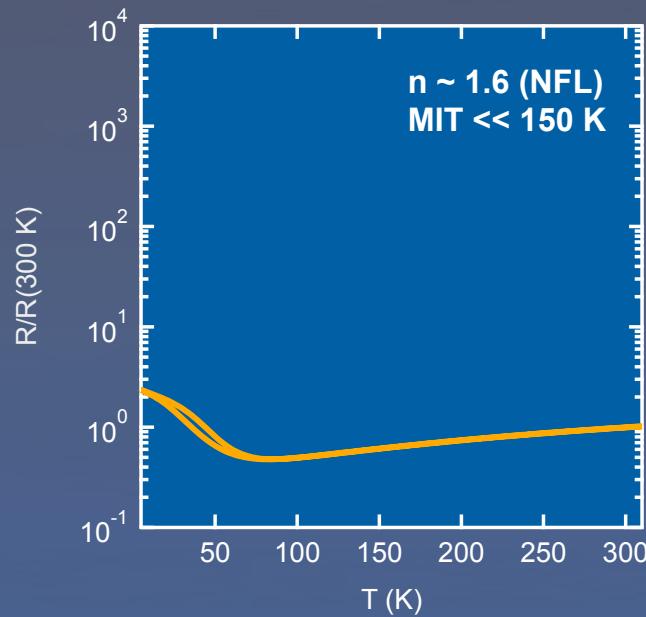
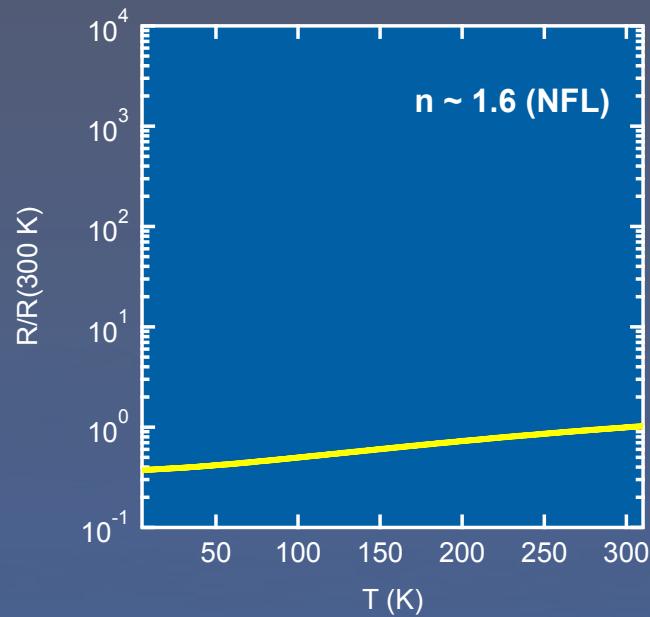


$$\frac{1}{\rho} = \frac{1}{\rho_0 + AT^n} + \frac{1}{\rho_{\text{sat}}}$$

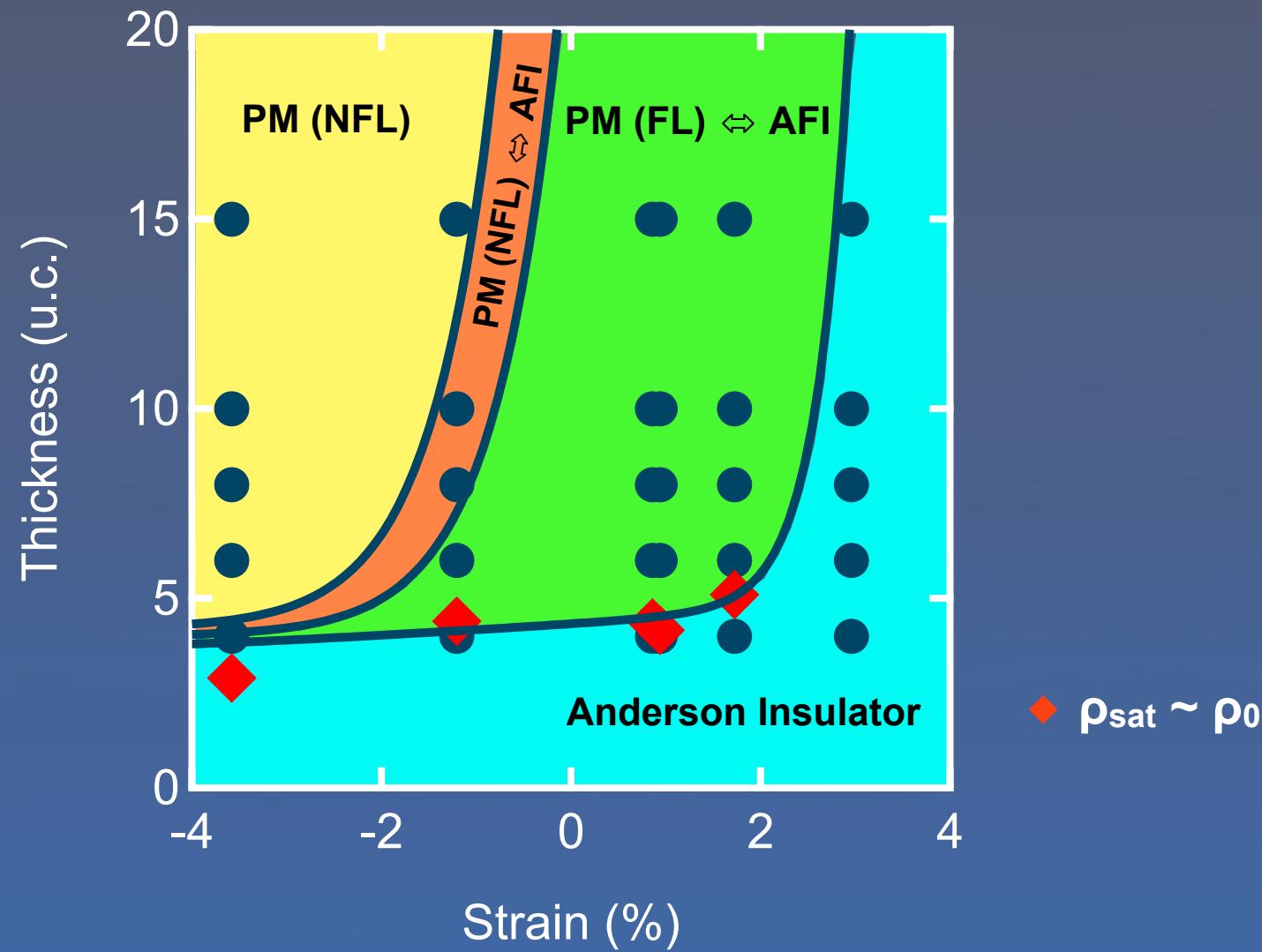
- $\rho_{\text{sat}}$  is independent of thickness but depends on strain
- $\rho_0$  depends on thickness
- Predict that material is insulating at all temperatures when  $\rho_{\text{sat}} \sim \rho_0$
- Correct to within 1 u.c.
- This Anderson insulator is strain and thickness tunable

# MITs and Non-Fermi Liquids

$$\frac{1}{\rho} = \frac{1}{\rho_0 + AT^n} + \frac{1}{\rho_{\text{sat}}}$$



# Phase Diagram



# Summary

- Single non-Fermi liquid exponent (5/3) across the entire series, if MIT is suppressed
- Non-Fermi liquid phase or quantum critical point?
- Need to take resistance saturation into account to get correct NFL exponent
- NdNiO<sub>3</sub> is a saturating metal, but Ioffe Regel Limit is exceeded
- Degree of “bad metal” behavior depends on orbital polarization (strain)
- Large orbital polarization increases  $\rho_{\text{sat}}$  and makes the material increasingly “non-saturating” → resistivity escalates past the Mott-Ioffe-Regel limit
- Can be tuned by strain and confinement
- Metals with large degeneracy have large  $\rho_{\text{sat}}$  and are thus non-saturating
- Quantitative understanding of the role of electronic structure in strongly correlated phenomena is desirable
- New routes to controlling MITs:
  - Confinement stabilizes spin-density wave and insulating state ⇒ modulate confinement
  - Strain can modulate transition between Anderson insulator and metal

Thank you

